Application No.	Applicant(s)	
10/664,718	STAIB, PHILIPPE	
Examiner	Art Unit	
Bernard E Souw	2881	
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	Bernard E Souw Pars on the cover sheet with (OR REMAINS) CLOSED in performing or other appropriate communication is so and MPEP 1308. 107/2004. The Examiner. Inder 35 U.S.C. § 119(a)-(d) or the examiner. Inder 35 U.S.C. § 119(a)-(d) or the examiner in the examiner	10/664,718 STAIB, PHILIPPE Examiner Art Unit Bernard E Souw 2881 Pars on the cover sheet with the correspondence address (OR REMAINS) CLOSED in this application. If not included or other appropriate communication will be mailed in due co (IGHTS. This application is subject to withdrawal from issue as and MPEP 1308. 107/2004. 1 the Examiner. 2 the been received. 2 been received in Application No 2 currents have been received in this national stage application of this communication to file a reply complying with the requirementation of this application. 1 the American Same North

DETAILED ACTION

EXAMINER'S AMENDMENT

1. An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

In the claims:

In claim 1, line 2, after "generating", prior to "electron beam", delete [an electron beam] and insert -- a high-energy collimated electron beam for diffraction applications --

Authorization for this Examiner's Amendment has been given during a phone conversation with the applicant's attorney, Mr. David M. Tener, Reg. No. 37,054, on September 24, 2004.

Applicant's Amendment

- 2. The Amendment filed 09/07/2004 has been entered. The present Office Action is made with all the arguments being fully considered.
 - Claims 2, 3 and 6 have been cancelled.
 - Claims 1, 4, 5, and 7-19 remain pending in this office action.

§ 112 Rejection Withdrawn

3. Claim 2 having been cancelled, the previous rejection under 35 U.S.C. §112, second paragraph, is now withdrawn.

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ALLOWANCE

4. Claims 1, 4, 5, and 7-19 are allowed.

The claims are subsequently renumbered to claims 1-16.

Reasons for Allowance

5. The following is an examiner's statement of reasons for allowance:

An electron source generating a high energy collimated electron beam for diffraction purposes, further comprising a first beam deflector and a second beam deflector separated by a distance that is greater than the distance from the second deflector to the sample, both deflectors being enclosed in a casing having an exit aperture that simultaneously serves as a barrier for gases from the sample region upon entering the lower pressure region inside the casing, as recited in claim 1, is neither anticipated nor rendered obvious by any prior art.

Claims 4, 5, and 7-19 are also allowed because of their dependencies, either directly or indirectly, upon claim 1.

6. Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Relevant Prior Art(s)

7. These prior art references made of record and not relied upon are considered pertinent to applicant's disclosure:

▶ USPAT # 6,677,581, issued on 01/13/2004 to Koinuma et al., is found to claim the

same subject matter as that of the present disclosure, including two stages of electron

beam deflectors 14 & 17 and a casing 22 having an aperture 15, shown in Fig.1 and

recited in Col.6/II.24-46. However, only one deflector 14 is enclosed inside the casing

22, while the other deflector 17 remains outside. Furthermore, the separation between

deflector 14 and deflector 17 is obviously larger than the distance between the second

deflector 17 to the sample 18.

▶ USPAT # 6,576,908, issued on 06/10/2003 to Winkler et al., is found to claim the

same subject matter as that of the present disclosure, including two stages of electron

beam deflectors 11 and 12 that are enclosed in a casing (labeled UHV) having an

aperture 8 that may further serve as a barrier for gases, as shown in Fig.2 and Fig.6,

recited in Col.4/II.36-65 and Col.5/II.11-15. However, as can be seen in all figure

drawings, Winkler's apparatus is not designed for high-energy electron diffraction as

recited in claim 1. Furthermore, the separation between Winkler's deflector 11 and

deflector 12 is obviously larger than the distance between the second deflector 12 to the

(unlabeled) sample at the bottom of the figure drawings.

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Communications

8. Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Bernard E Souw whose telephone number is 571 272

2482. The examiner can normally be reached on Monday thru Friday, 9:00 am to 5:00

pm..

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, John R Lee can be reached on 571 272 2477. The central fax phone

number for the organization where this application or proceeding is assigned is (703)

872-9306 for regular communications as well as for After Final communications.

Any inquiry of a general nature or relating to the status of this application or

proceeding should be directed to the receptionist whose telephone number is 703 308

0956.

bes

September 24, 2004

JOHN R. LEE

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SUPERVIZORY PATENT EXAMINER

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